

Supporting Information

A Mechanistic Study into the Catalytic Effect of $\text{Ni}(\text{OH})_2$ on Hematite for Photoelectrochemical Water Oxidation

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Experimental section

Synthesis of hematite ($\alpha\text{-Fe}_2\text{O}_3$) nanowire arrays:

Akaganéite ($\beta\text{-FeOOH}$) nanowire arrays were grown on a fluorine-doped tin oxide (FTO, TEC 8) glass substrate using a hydrothermal method reported elsewhere ¹. A Teflon-lined stainless steel autoclave was filled with 20 mL 0.15M FeCl_3 and 1M NaNO_3 aqueous solution at pH 1.5 (adjusted by HCl). A cleaned FTO substrate was placed into the autoclave with the conductive side facing down. The sealed autoclave was heated at 95 °C for 5h in an electric oven and allowed it to cool down in air. A uniform yellow layer of $\beta\text{-FeOOH}$ nanowire arrays was coated on the FTO glass. The nanowire-coated FTO glass was washed with ethanol and water, and then air dry. $\alpha\text{-Fe}_2\text{O}_3$ nanowire arrays were obtained by thermal decomposition $\beta\text{-FeOOH}$ nanowire. The $\beta\text{-FeOOH}$ nanowires were annealed in a home-built CVD system. The tube furnace was first vacuumed to a pressure of 15 Torr, and then filled with ultrahigh purity N_2 ¹. The sample was annealed at 550 °C for 2h at 740 Torr pressure with a N_2 gas flow of 50 sccm.

Deposition of Ni(OH)_2 catalyst:

Ni(OH)_2 was deposited onto hematite nanowire arrays by successive dip coating method ². The hematite nanowire electrode was first dipped into 0.1 M $\text{Ni(NO}_3)_2$ solution for 10 seconds, and blow-dried with compressed air. Then the electrode was dipped into 1.0 M KOH solution for 10 seconds, and blow-dried with compressed air. This two-step dip-coating process was repeated for 3 times. For the sample with small loading of Ni catalyst, we used 5 mM $\text{Ni(NO}_3)_2$ solution and repeated the deposition cycles for 2 times only.

Material characterization:

Scanning electron microscopy (SEM) images and energy dispersive X-ray spectroscopy (EDS) spectra were collected on a field emission SEM (Hitachi S-4800II). X-ray diffraction (XRD) spectra of hematite and blank FTO glass were collected on a Rigaku Americas Miniflex Plus powder diffractometer with the angle from 20 to 70 degree. X-ray photoelectron spectroscopy (XPS, ESCALab 250, Thermo VG) with 200W Al K α radiation in twin anode. The binding energy was calibrated using the C 1s at 284.6 eV as a reference. Electrochemical and photoelectrochemical measurements were carried out using an electrochemical workstation CHI 660D coupled with a 150W xenon lamp (Newport 6255) and an AM 1.5 global filter (Newport 81094). The electrolyte was 1.0 M KOH aqueous solution. Ag/AgCl (1 M KCl) and Pt wire were used as reference and counter electrode in the three-electrode system.

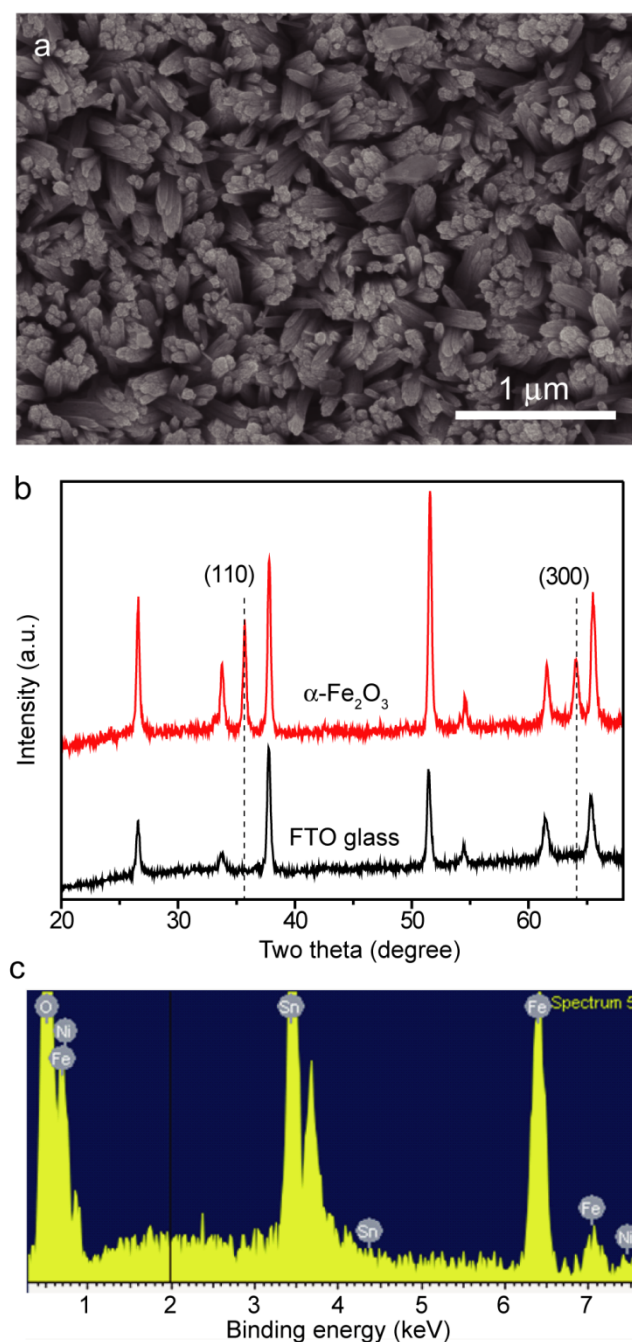


Figure S1. (a) SEM image of hematite nanowire arrays grown on a FTO glass substrate. (b) XRD spectra collected for hematite nanowires coated FTO substrate and a blank FTO substrate. The dashed lines highlight the (110) and (300) diffraction peaks of hematite. (c) EDS spectrum collected for the Ni(OH)_2 decorated hematite film.

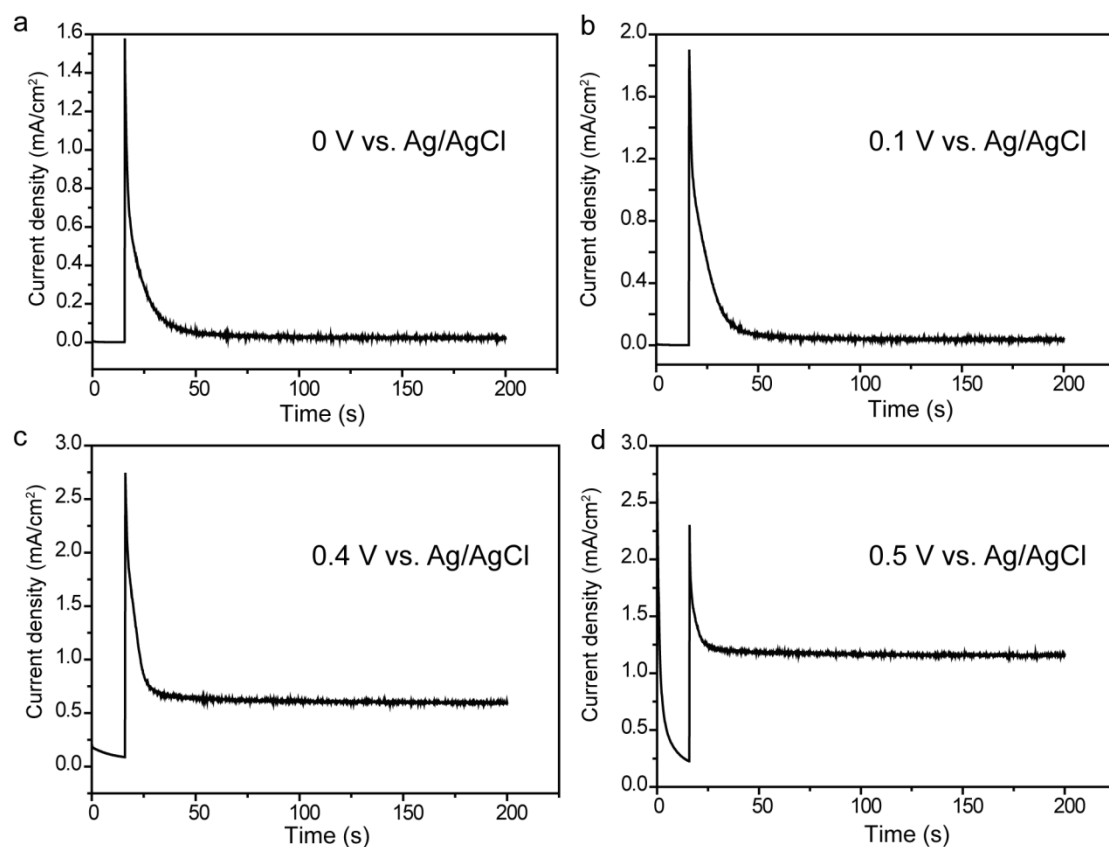


Figure S2. Photocurrent densities vs. time (j - t) curves of the Ni-Fe₂O₃ electrode collected in 1.0 M KOH solution at different potentials. The dark currents observed in (c) and (d) are due to the electrochemical oxidation of Ni(OH)₂ (Ni²⁺/Ni³⁺), which occurs at around 0.35V vs. Ag/AgCl.

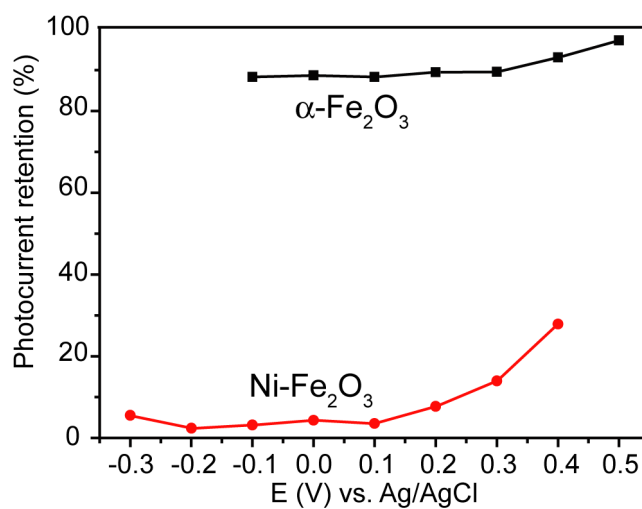


Figure S3. Current density retention measured for pristine α -Fe₂O₃ and Ni-Fe₂O₃ at the scan

rate of 50 mV/s.

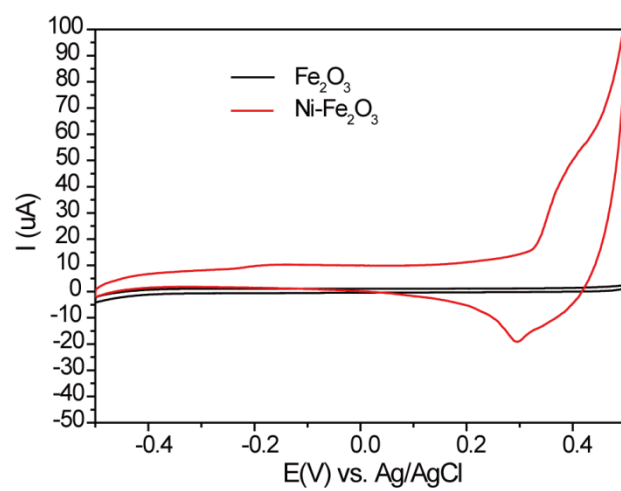


Figure S4. Cyclic voltammograms of $\alpha\text{-Fe}_2\text{O}_3$ and $\text{Ni-Fe}_2\text{O}_3$ in the absence of glucose in 1.0 M KOH solution at the scan rate of 50 mV/s.

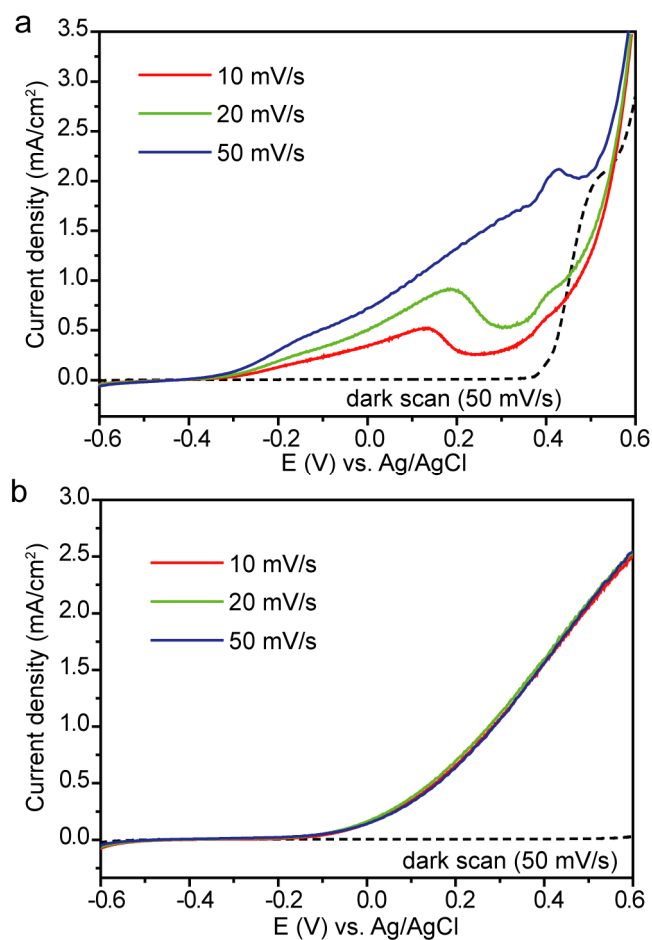


Figure S5. Linear sweep voltammograms of (a) Ni-Fe₂O₃ and (b) α-Fe₂O₃ collected in 1.0 M KOH solution at a scan rate of 10, 20, and 50 mV/s under light illumination (AM 1.5G 100 mW/cm²). The dashed lines are the dark scans collected at 50 mV/s.

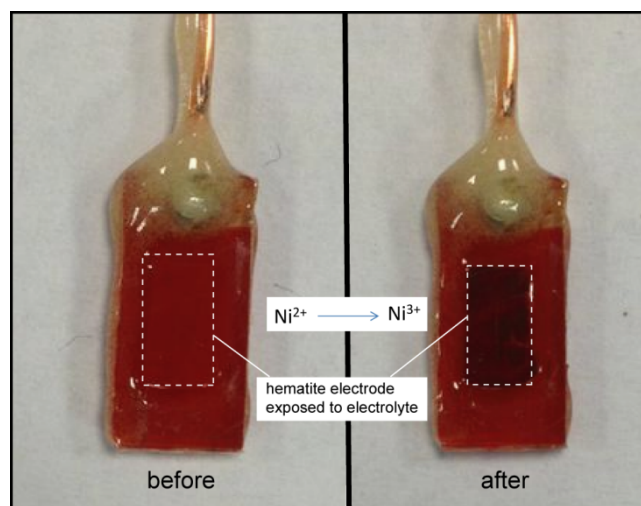


Figure S6. Digital pictures collected for Ni-Fe₂O₃ electrode before and after irradiated with white light (AM 1.5G, 100 mW/cm²) at 0.3V vs. Ag/AgCl for 200 seconds.

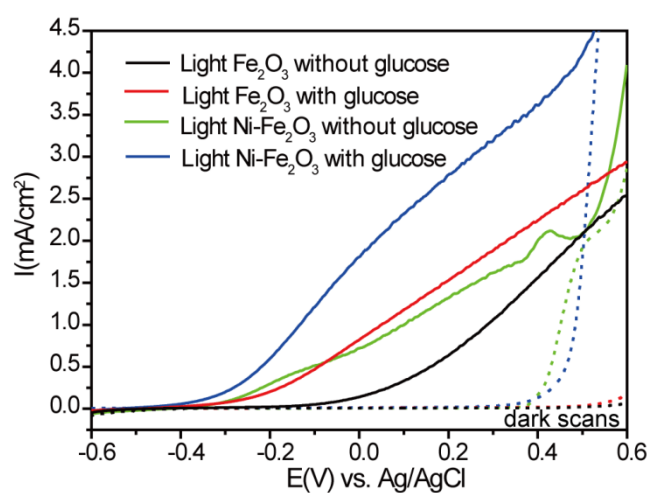


Figure S7. Linear sweep voltammograms of Fe₂O₃ and Ni-Fe₂O₃ collected in 1.0 M KOH solution at a scan rate of 50 mV/s, in the presence and absence of glucose. Solid and dashed lines are *j*-*V* curves collected, light illumination (AM 1.5G, 100 mW/cm²) and in the dark.

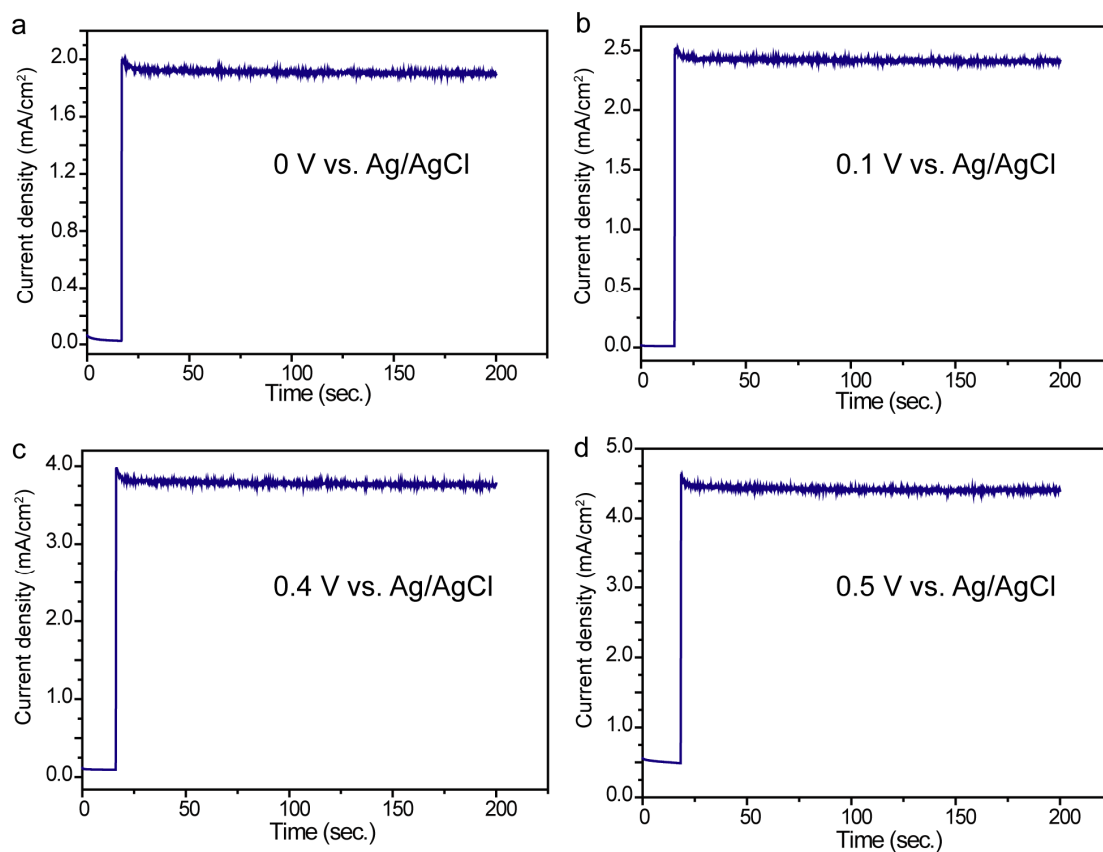


Figure S8. (a-d) Photocurrent densities vs. time curves collected for Ni-Fe₂O₃ in 1.0 M KOH solution in the presence of 0.1 M glucose at different potentials.

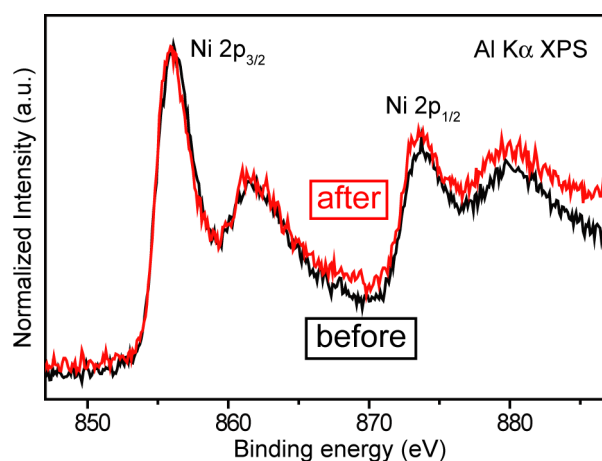


Figure S9. Overlay of the normalized Ni 2p XPS spectra collected for Ni-Fe₂O₃ before (black curve) and after (red curves) light illumination in the presence of glucose at 0.3 V vs. Ag/AgCl for 200 seconds.

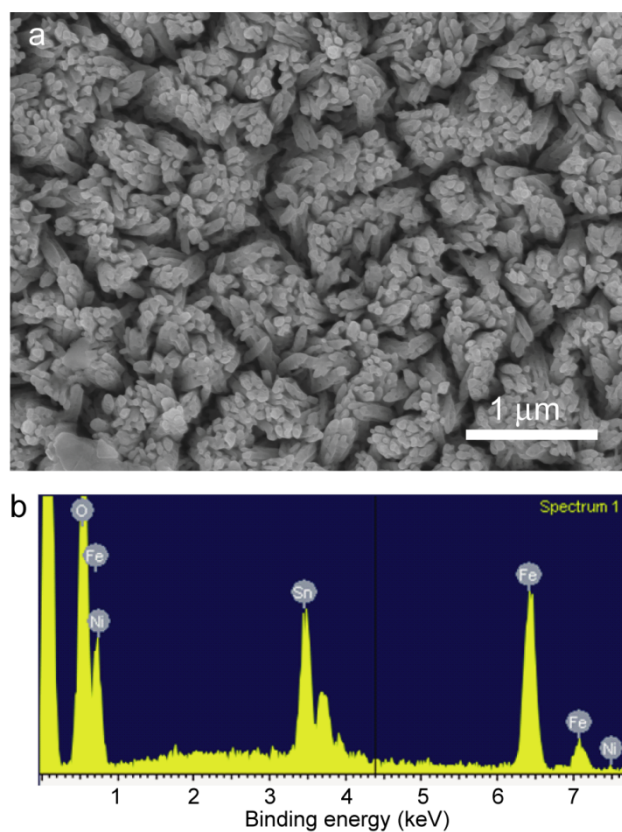


Figure S10. (a) SEM image of Ni-Fe₂O₃ electrode with small loading of Ni(OH)₂ catalyst. (b) Corresponding EDS spectrum collected for the Ni-Fe₂O₃ electrode.

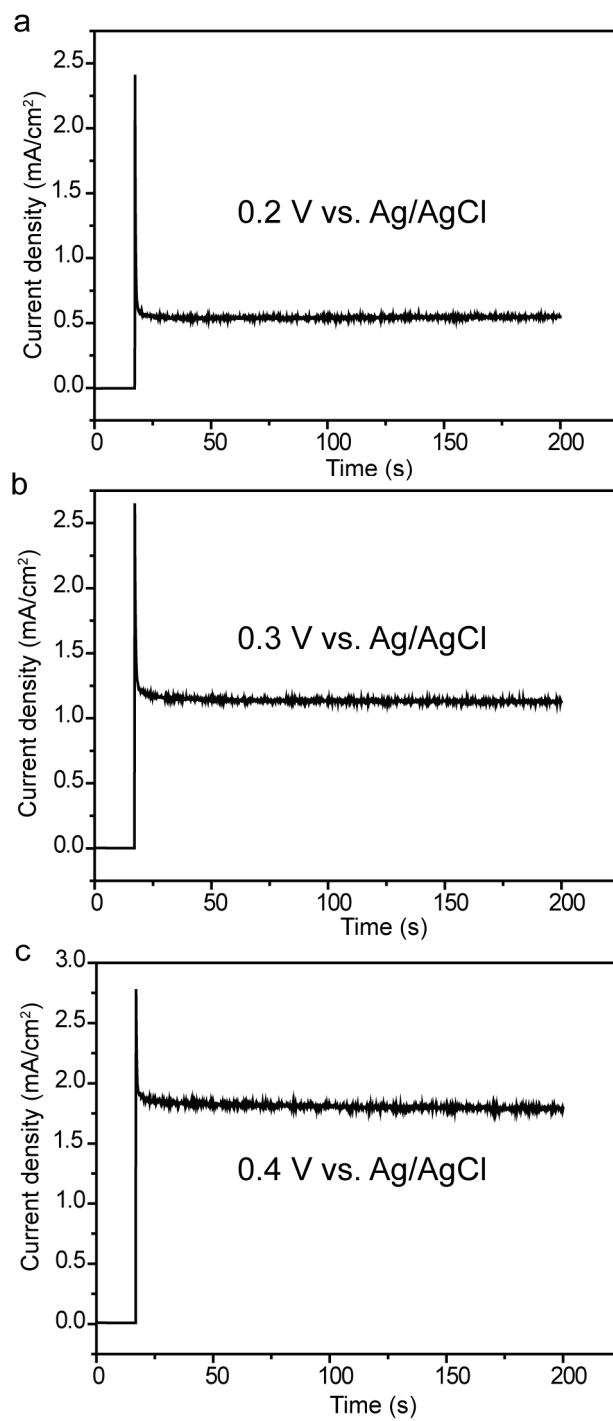


Figure S11. Current densities vs. time curves of s-Ni-Fe₂O₃ measured in 1.0 M KOH solution (without glucose) at different potentials.

References

1. Y. C. Ling, G. M. Wang, J. Reddy, C. C. Wang, J. Z. Zhang and Y. Li, *Angew. Chem. Int. Ed.*, 2012, **51**, 4074-4079.
2. G. M. Wang, Y. C. Ling, X. H. Lu, H. Y. Wang, F. Qian, Y. X. Tong and Y. Li, *Energy Environ. Sci.*, 2012, **5**, 8215-8219.